# Effect of adding oxygen to thin-film silicongermanium micro-crystalline solar cells

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To increase the efficiency of thin-film silicon solar cells, a larger portion of the spectrum has to be absorbed. Ideal device: a multi-junction solar cell, with amorphous silicon absorbing the blue part of the spectrum, microcrystalline silicon (µc-Si) for the rest of the visible spectrum and microcrystalline silicon-germanium  $(\mu c-Si_xGe_{1-x})$  for the infrared.

The aim of this work is to optimise the  $\mu$ c-Si<sub>x</sub>Ge<sub>1-x</sub> intrinsic layer to get a suitable bottom cell. So single junction p-i-n cells were deposited on textured zinc oxide.

### Effect of germanium content:

- Higher light absorption coefficient.
- Better IR absorption due to lower band-gap.
- If the Ge content is too high, the photo-generated carrier collection decreases



## Effect of i-layer thickness:

- Thicker layers have a higher IR absorption.
- If thicker than 2 µm, short circuit current decreases.
- The quantum efficiency in the blue region of the spectrum decreases in thick layers.

ZnO

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a-Si cell: large band-gap

µc-Si cell: medium band-gap

µc-Si<sub>x</sub>Ge<sub>1-x</sub> cell: small band-gap



 $\rightarrow$  The IR absorption of  $\mu$ c-Si<sub>x</sub>Ge<sub>1-x</sub> cells is limited because the germanium content and the i-layer thickness are limited. The photo-generated carrier collection has to be improved to turn these cells into valuable bottom cells.

### Effect of oxygen doping

Oxygen is added to the intrinsic layer as a dopant:

- The amount is too low to change the intrinsic character of the material.
- It does not have any effect on the film dark conductivity.

However, it has an impact on the cell performance:

- The blue response increases.
- There is an optimal concentration: when there is too much oxygen, the red response decreases.
- It has more impact on thicker cells.









With the right amount of CO<sub>2</sub>, a better photogenerated charge collection is achieved, especially near the p/i interface. This translates to a higher short-circuit current and efficiency. At the optimum doping level, the oxygen concentration in the intrinsic layer is around  $1 \cdot 10^{19}$  -  $2 \cdot 10^{19} \, cm^{\text{-3}}.$  For a 3  $\mu m$  cell, the  $J_{sc}$  gain is 3.9 mA/cm<sup>2</sup>.



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